## IN THE CLAIMS:

Please amend claims 1-4 as shown in the complete list of claims that is presented below.

a plurality of

1. (currently amended) A layout of a flash memory having symmetric select transistors, comprising:

> a memory cell array; the select transistors a ride of a polysilicon gates extending in a direction perpendicular to the memory cell array and cooperating with a plurality of pairs of sources/drains arranged at two sides thereof for forming a plurality

a wires connecting the plurality of select transistors and the memory cell array.

2. (currently amended) The layout according to claim 1, wherein the wires comprises a segments parallel to the polysilicon gates.

a plurality of

3. (currently amended) A layout of a flash memory having symmetric select transistors, comprising:

> a memory cell array; and extending in a direction perpendicular to the memory cell array; wherein the plurality of select transistors are arranged substantially symmetric with respect to the memory cell array.

4. (currently amended) The layout according to claim 3, further comprising a metal wires extending from the memory cell array toward the polysilicon gates for connecting the plurality of select transistors to a bit line of the memory cell array.

**AMENDMENT** 

10/643,876

## IN THE CLAIMS:

Please amend claims 1-4 as shown in the complete list of claims that is presented below.

a plurality of

1. (currently amended) A layout of a flash memory having symmetric select transistors, comprising:

a memory cell array; the plurality of symmilic transistors a polysilicon gates extending in a direction perpendicular to the memory cell array and cooperating with a plurality of pairs of sources/drains arranged at two sides thereof for forming a plurality of select transistors; and

a wires connecting the plurality of select transistors and the memory cell array.

- 2. (currently amended) The layout according to claim 1, wherein the wires comprises a segments parallel to the polysilicon gates.
- 3. (currently amended) A layout of a flash memory having symmetric select transistors, comprising:

a memory cell array; and

a polysilicon gates corresponding to a plurality of select transistors

extending in a direction perpendicular to the memory cell array;

wherein the plurality of select transistors are arranged substantially

symmetric with respect to the memory cell array.

4. (currently amended) The layout according to claim 3, further comprising a metal wires extending from the memory cell array toward the polysilicon gates for connecting the plurality of select transistors to a bit line of the memory cell array.